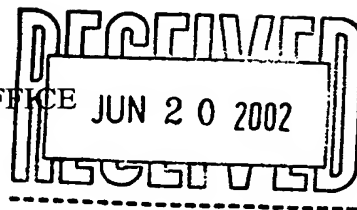


43340



PATENT



In re Application of:

Jong-Dal HONG et al.

Group Art Unit: 1762

Serial No.: 10/050,599

Filed: January 18, 2002

For: A PROCESS FOR FABRICATING
MONOLAYER/MULTILAYER
ULTRATHIN FILMS



SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

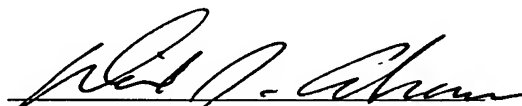
Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:

In accordance with 37 C.F.R. § 1.97 and § 1.98, Applicants bring the disclosures attached and listed on completed Form PTO-1449 to the Examiner's attention and request that they be considered and made of record in this application.

Prompt examination on the merits is respectfully requested.

Respectfully submitted,


David S. Abrams
Reg. No. 22,576

Roylance, Abrams, Berdo & Goodman, L.L.P.
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Dated: June 13, 2002

[illegible]

Form PTO-1449		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE			ATTY. DOCKET NO. 43340		SERIAL NO. 10/050,599	
INFORMATION DISCLOSURE CITATION (Use several sheets if necessary)					APPLICANT Jong-Dale Hong et al.			
					FILING DATE January 18, 2002		GROUP 1762	

U.S. PATENT DOCUMENTS											
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE					

FOREIGN PATENT DOCUMENTS									
DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION				
					YES	NO			

OTHER DOCUMENTS (including Author, Title, Date, Pertinent Pages, Etc.)	
	"Mechanism of and Defect Formation in the Self-Assembly of Polymeric Polycation-Montmorillonite Ultrathin Films", Kotov et al., J. Am. Chem. Soc., 1997, 119, 6821-6832.
	"Electroluminescence Studies on Self-Assembled Films of PPV and CdSe Nanoparticles", Gao et al., J. Phys. Chem. B. 1998, 102, 4096-4103.

EXAMINER	DATE CONSIDERED
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*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw Line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.